MOOV

Configuration check sheet

1	Check Date		Inspector		
2	End User				
3	Machine Model	**NSR- 4425i**			
4	Electric source	(without/with) NEMA BOX / For (CVCF/UPS) / **NEMA Switch**(none/**1**/2)			
5	Chamber Type	Maker	ASAHI / SENDAI	Production date	**1997. 11**
				Model	**N3A-B**
6	Chamber Size	Long Body(1950mm) / **Short Body(1800mm)**		Chamber EPROM Ver.	
7	Set Teperature	**Chamber : 23.0**	**LLTC:** ℃	**IATC: 23.00**	
		IATC(X): ℃	IATC(Y): ℃		
8	Computer Type	**Vax** / Alpha Station / DMCC		Computer Model	**4000. 96**
9	MCSV Ver.	**2.31D**	OCSV Ver.	**2.31A**	
	TOOL Ver.	**2.43B**	BASEKIT Ver.	**BASE7M_111_9903A**	
10	ROM Version	**ST - 71 V6.20**	**AL - 71 V9.50**	**PA - 71 V5.40**	
		LC - 7M V3.00	**RL - 04 V5.60**	**AWL - 10 V4.80**	
		SEN - 10 V1.10	**OF- G3 V2.76**	INL	
		PPD			
11	HP LASER	5517A / **5517B** / 5517C / 5517D		LSA LASER	**5mW** / 10mW
12	Reticle Microscope	**Fixed (O)**/ Variable (mm to mm) / **setting size (44mm)**			
13	Wafer Condition	Sapphire / **Silicon** / Other( )			
14	OF Detection Type	**Nikon Original Type** / Omron type / Keyence type		**Flat** / Notch	
15	Wafer Loader Type	TYPE1 / **TYPE2** (A1 / A3 / G3/ B3) / TYPE3		Wafer size : 4, 6, **8 inch**	
16	Wafer Carrier Table	**Left / Right** / Extra		In-line	**no** / yes (right / left)
17	Reticle Size	5inch(32mm /26mm/18mm) **/6inch**		FIA / BCR	no , **yes** /**no** , yes
18	Reticle Library Type	**Nikon** / Canon	Slot	**Main : (13)slot** / Ext. LIB ( )slot	
19	PPD /PD	PPD (**no**/yes)	PD(**no**/yes)		
20	Rack Type	Normal (**Right** / Left) / Special Left			
21	SHRINC Type	**None** / 1 / 2 / 3	Illumination Setting	Attachment Setting Value	
22	Cymer Laser Maker /Type	/			
23	BMU Type	Under Flow / Over Flow		BMU Model	
24	BMU Picture	Attachment BMU Picture or drawing			
25	Backup Method	FULL / **Only Constants DKA200**		Backup Date	
	NOTE				